SHIGA7.034APC PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant

Washio et al.

Appl. No.

10/560,155

Filed

December 9, 2005

For

DEVELOPER COMPOSITION FOR RESISTS AND METHOD FOR FORMATION OF RESIST

PATTERN

Examiner

Le, Hoa Van

Group Art Unit

1752

AMENDMENT AND RESPONSE TO FINAL OFFICE ACTION

Mail Stop AF

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

In response to the final Office Action mailed **January 18, 2007**, Applicants respectfully request consideration of the following amendments and remarks:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks/Arguments begin on page 3 of this paper.